L	Hits	Search Text	DB	Time stamp
Number	252	(silicon adj (dioxide or oxide)) same	USPAT;	2002/07/26
_	253	epitax\$4 and 117/\$4.ccls.	US-PGPUB;	15:34
		epitax\$4 and 117/\$4.0018.	EPO; JPO;	15.54
			DERWENT;	
			IBM TDB	
_	113	(silicon adj (dioxide or oxide)) same	USPAT;	2002/07/26
	113	epitax\$4 and 117/\$4.ccls. and cvd	US-PGPUB;	15:36
		opiount and in the second seco	EPO; JPO;	
			DERWENT;	•
	•		IBM TDB	:
-	66		USPAT;	2003/12/16
		epitax\$4 and 117/\$4.ccls. and cvd	US-PGPUB;	15:36
			EPO; JPO;	
	1		DERWENT;	·
			IBM_TDB	2222/25
-	375	(silicon adj (dioxide or oxide)) near40	USPAT;	2002/07/26
		crystal\$5 and 117/\$4.ccls.	US-PGPUB;	15:51
			EPO; JPO;	
			DERWENT;	
	140	(silicon adj (dioxide or oxide)) near40	IBM_TDB USPAT;	2002/07/26
_	140	crystal\$5 and 117/\$4.ccls. and cvd	US-PGPUB;	17:30
		Crystarys and 117/34.ccrs. and evd	EPO; JPO;	17.30
			DERWENT;	
			IBM TDB	
-	2	ethyl\$1silicate and 117/\$4.ccls.	USPAT;	2002/07/26
	-		US-PGPUB;	17:37
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	6		USPAT;	2003/12/16
		near2 (gan or zno or gallium adj nitride	US-PGPUB;	14:54
		or zinc adj oxide)	EPO; JPO;	
			DERWENT;	
	3,		IBM_TDB USPAT;	2003/12/16
_	70	quartz near2 (layer or film) same (gan or zno or gallium adj nitride or zinc adj	USPAT; US-PGPUB;	15:19
	:	oxide)	EPO; JPO;	10.15
		oniuc,	DERWENT;	
			IBM TDB	
_	87	quartz near2 (layer or film) same buffer	USPAT;	2003/12/17
			US-PGPUB;	11:03
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	2	quartz near2 buffer and (zno or zinc adj	USPAT;	2003/12/16
		oxide or gan or gallium adj nitride)	US-PGPUB;	15:34
		near10 buffer	EPO; JPO;	
			DERWENT;	
	0.0	/wiliam add (diowide as assidal) massage	IBM_TDB USPAT;	2003/12/16
	88	(silicon adj (dioxide or oxide)) near20	USPAT; US-PGPUB;	15:45
		epitax\$4 and 117/\$4.ccls. and cvd	EPO; JPO;	10.70
,			DERWENT;	
			IBM TDB	
		I		<u></u>